

# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

| APPLICATION NO.                | FILING DATE     | FIRST NAMED INVENTOR | ATTORNEY DOCKET NO.    | CONFIRMATION NO. |
|--------------------------------|-----------------|----------------------|------------------------|------------------|
| 10/762,849                     | 01/22/2004      | Matthew Prince       | ITL.0941US (P15694)    | 5852             |
| 21906                          | 7590 08/15/2005 |                      | EXAM                   | INER             |
| TROP PRUNER & HU, PC           |                 |                      | SHAKERI, HADI          |                  |
| 8554 KATY FREEWAY<br>SUITE 100 |                 |                      | ART UNIT               | PAPER NUMBER     |
| HOUSTON, TX 77024              |                 |                      | 3723                   |                  |
|                                |                 |                      | DATE MAILED: 08/15/200 | 5                |

Please find below and/or attached an Office communication concerning this application or proceeding.

|   | Application No.   | Applicant(s)   |  |
|---|---|--|--|
|   | 10/762,849  | PRINCE ET AL.  |  |
| Office Action Summary   | Examiner  | Art Unit   |  |
|   | Hadi Shakeri  | 3723   |  |
| The MAILING DATE of this communicat Period for Reply  |   | 1  |  |
| A SHORTENED STATUTORY PERIOD FOR THE MAILING DATE OF THIS COMMUNICA:  - Extensions of time may be available under the provisions of 37 after SIX (6) MONTHS from the mailing date of this communica:  - If the period for reply specified above is less than thirty (30) da:  - If NO period for reply is specified above, the maximum statutor:  - Failure to reply within the set or extended period for reply will, Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b). | TION.  CFR 1.136(a). In no event, however, may a ration.  ys, a reply within the statutory minimum of thin y period will apply and will expire SIX (6) MON by statute, cause the application to become AE | reply be timely filed  ty (30) days will be considered timely.  ITHS from the mailing date of this communication.  BANDONED (35 U.S.C. & 133). |  |
| Status  |   |  |  |
| 1) Responsive to communication(s) filed or  | n   | •  |  |
|   | ☐ This action is non-final.   |  |  |
| 3) Since this application is in condition for   | allowance except for formal matt  | ers, prosecution as to the merits is   |  |
| closed in accordance with the practice u  | nder <i>Ex parte Quayl</i> e, 1935 C.D  | . 11, 453 O.G. 213.  |  |
| Disposition of Claims   |   |  |  |
| 4)⊠ Claim(s) <u>1-20</u> is/are pending in the appli  | cation.   |  |  |
| 4a) Of the above claim(s) is/are w  |   |  |  |
| 5) Claim(s) is/are allowed.   |   |  |  |
| 6)⊠ Claim(s) <u>1-20</u> is/are rejected.   |   |  |  |
| 7) Claim(s) is/are objected to.   |   |  |  |
| 8) Claim(s) are subject to restriction  | and/or election requirement.  |  |  |
| Application Papers  |   |  |  |
| 9)⊠ The specification is objected to by the Ex  | aminer.   |  |  |
| 10)⊠ The drawing(s) filed on 22 January 2004  |   | bjected to by the Examiner.  |  |
| Applicant may not request that any objection  | to the drawing(s) be held in abeyan   | ce. See 37 CFR 1.85(a).  |  |
| Replacement drawing sheet(s) including the  | correction is required if the drawing(  | s) is objected to. See 37 CFR 1.121(d)   |  |
| 11)☐ The oath or declaration is objected to by  | the Examiner. Note the attached   | Office Action or form PTO-152.   |  |
| Priority under 35 U.S.C. § 119  |   |  |  |
| 12) Acknowledgment is made of a claim for for a) All b) Some * c) None of:  | •   | 119(a)-(d) or (f).   |  |
| 1. Certified copies of the priority docu  |   |  |  |
| 2. Certified copies of the priority doct  |   | · · · · · · · · · · · · · · · · · · ·  |  |
| 3. Copies of the certified copies of the  | •   | received in this National Stage  |  |
| application from the International E  * See the attached detailed Office action for   | •   | rossivad   |  |
| See the attached detailed Office action for   | a list of the certified copies flot i   | eceivea.   |  |
| Attachment(s)   |   |  |  |
| ) Notice of References Cited (PTO-892) ) Notice of Draftsperson's Patent Drawing Review (PTO-9  |   | ummary (PTO-413)<br>)/Mail Date  |  |

U.S. Patent and Trademark Office PTOL-326 (Rev. 1-04)

Notice of Draftsperson's Patent Drawing Review (PTO-948)
 Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)
 Paper No(s)/Mail Date \_\_\_\_\_.

6) Other: \_

5) Notice of Informal Patent Application (PTO-152)

Application/Control Number: 10/762,849 Page 2

Art Unit: 3723

#### **DETAILED ACTION**

## **Drawings**

1. Figure 1 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g). Corrected drawings in compliance with 37 CFR 1.121(d) are required in reply to the Office action to avoid abandonment of the application. The replacement sheet(s) should be labeled "Replacement Sheet" in the page header (as per 37 CFR 1.84(c)) so as not to obstruct any portion of the drawing figures. If the changes are not accepted by the examiner, the applicant will be notified and informed of any required corrective action in the next Office action. The objection to the drawings will not be held in abeyance.

## Specification

2. The disclosure is objected to because of the following informalities: page 2, line 2, describes the figure as an embodiment of the present invention, whereas it only discloses a wafer covered by dielectric layers (14, 16), barrier layer (18) and copper layer (20) filling the trench (22); all known in the art as admitted by the Applicant on page 1.

Appropriate correction is required.

## Claim Rejections - 35 USC § 102

3. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- 4. Claims 16, 17, 19 and 20 are rejected under 35 U.S.C. 102(b) as being clearly anticipated by Tredinnick et al. (3,715,842).

Art Unit: 3723

Tredinnick et al. discloses all of the limitations of claim 16, i.e., aging a silica slurry for at least fifty days (12 weeks) from its manufacture date and using to CMP a layer, wherein the layer is non-metallic, i.e., silicon wafer.

## Claim Rejections - 35 USC § 103

- **5.** The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 6. Claims 11, 12 and 18 are rejected under 35 U.S.C. 102(b) as anticipated by Tredinnick et al. or, in the alternative, under 35 U.S.C. 103(a) as obvious over Tredinnick et al. in view of Applicant's Admitted Prior Art (AAPA).

Tredinnick et al. as described above discloses all of the limitations of claim 11, i.e., aging a silica slurry for at least fifty days (12 weeks) from its manufacture date and using to CMP a metallic layer, i.e., metalloid germanium, however in the alternative, it is known in the art to use silica slurry in the CMP step of damascene process in manufacturing semiconductor integrated circuits as admitted by Applicant on page 1. It would have been obvious to one of ordinary skill in the art, at the time the invention was made, to use the silica slurry with the thickening agent as disclosed by Tredinnick et al., in the damascene process to define a copper line in a trench, as this process is known in the art, in prevention of scratching the workpiece.

7. Claims 1-10 and 13-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Tredinnick et al. in view of AAPA.

Application/Control Number: 10/762,849

Art Unit: 3723

Tredinnick et al. meets all of the limitations of claims 1 and 6, as explained above, except for using it on a tantalum containing layer. As indicated in section 6, it would have been obvious for one of ordinary skill in the art to use the slurry of Tredinnick et al. in a damascene process, which meets the limitations as recited.

Page 4

#### **Conclusion**

8. Prior art made of record and not relied upon are considered pertinent to applicant's disclosure. Avanzino et al., Roth, Kim et al., and Shimamoto et al. are cited to show related inventions.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Hadi Shakeri whose telephone number is (571) 272-4495. The examiner can normally be reached on Monday-Thursday.

The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Hadi Shakeri

Primary Examiner

Art Unit 3723

August 11, 2005